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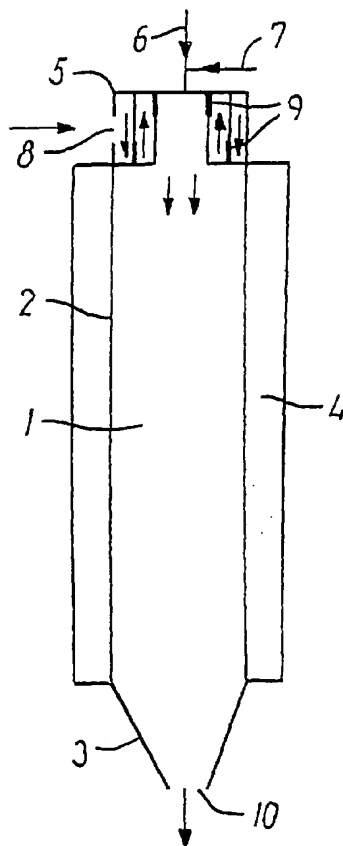
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(54) Title: A METHOD AND APPARATUS FOR PRODUCING MICRO PARTICLES

(57) Abstract: The invention relates to a method and apparatus for producing substantially monodisperse micro particles preferably of heat sensible material using a carrier gas and a drying gas. Relatively dense micro particles with diameters in the range 1-120µm with a very narrow span.



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